

CLAIM AMENDMENT:

Please amend claim 35 and cancel claims 57 - 91

Claim 1 (original): A sealing apparatus for sealing a semiconductor wafer having semiconductor elements on its surface by resin, comprising:

an upper mold; and

a lower mold having an area where the semiconductor wafer is mounted, the lower mold having an uneven surface in the area.

Claim 2 (original): A sealing apparatus as claimed in claim 1, wherein the uneven surface is formed by an electric discharging process in coarse condition.

Claim 3 (original): A sealing apparatus as claimed in claim 2, wherein the area is a first area, the uneven surface is formed within a second area, which is in the first area, and the uneven surface is not formed in the periphery of the first area.

Claim 4 (original): A sealing apparatus as claimed in claim 2, wherein the uneven surface has a roughness in a range between 8 μ m and 12 μ m.

Claim 5 (original): A sealing apparatus as claimed in claim 3, wherein the uneven surface has a roughness in a range between 8 μ m and 12 μ m.

Claim 6 (original): A sealing apparatus as claimed in claim 1, wherein the uneven surface is formed by slits.

Claim 7 (original): A sealing apparatus as claimed in claim 6, wherein the slits are formed in parallel to each other.

Claim 8(original): A sealing apparatus as claimed in claim 6, wherein the area is a first area, the slits is formed within a second area, which is in the first area, and the slits are not extended to the periphery of the first area.

Claim 9 (original): A sealing apparatus as claimed in claim 7, wherein the area is a first area, the slits is formed within a second area, which is in the first area, and the slits are not extended to the periphery of the first area.

Claim 10 (original): A sealing apparatus as claimed in claim 1, wherein the uneven surface is formed by a single spiral slit.

Claim 11 (original): A sealing apparatus as claimed in claim 10, wherein the area is a first area, the single spiral slit is formed within a second area, which is in the first area, and the single spiral slit is not extended to the periphery of the first area.

Claim 12 (original): A sealing apparatus as claimed in claim 1, further comprising a shock absorber, which is formed under the lower mold, buffering

stress from the upper mold when the semiconductor wafer is sandwiched by the upper and lower molds.

Claim 13 (original): A sealing apparatus as claimed in claim 1, further comprising shock absorbers which are formed under the lower mold, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold, the shock absorbers being disposed symmetrically against the center of the area.

Claim 14 (original): A sealing apparatus as claimed in claim 12, wherein the shock absorber is formed by a metallic compression spring.

Claim 15 (original): A sealing apparatus as claimed in claim 13, wherein each shock absorber is formed by a metallic compression spring.

Claim 16 (original): A sealing apparatus as claimed in claim 12, wherein the shock absorber is a first shock absorber, further comprising:

- a first block having a first recess, the lower mold being contained in the first recess;

- a second block having a second recess, the first block being contained in the second recess; and

- a second shock absorber, which is formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 17 (original): A sealing apparatus as claimed in claim 12 wherein the shock absorber is a first shock absorber, further comprising:

a first block having a first recess, the lower mold being contained in the first recess;

a second block having a second recess, the first block being contained in the second recess; and

second shock absorbers, which are formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 18 (original): A sealing apparatus as claimed in claim 16, wherein the second shock absorber is formed by a metallic compression spring.

Claim 19 (original): A sealing apparatus as claimed in claim 17, wherein each second shock absorber is formed by a metallic compression spring.

Claim 20 (original): A sealing apparatus as claimed in claim 13, wherein the shock absorbers are first shock absorbers, further comprising:

a first block having a first recess, the lower mold being contained in the first recess;

a second block having a second recess, the first block being contained in the second recess; and

a second shock absorber, which is formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 21 (original): A sealing apparatus as claimed in claim 13, wherein the shock absorbers are first shock absorbers, further comprising:

a first block having a first recess, the lower mold being contained in the first recess;

a second block having a second recess, the first block being contained in the second recess; and

second shock absorbers, which are formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 22 (original): A sealing apparatus as claimed in claim 20, wherein the second shock absorber is formed by a metallic compression spring.

Claim 23 (original): A sealing apparatus as claimed in claim 21, wherein each second shock absorber is formed by a metallic compression spring.

Claim 24 (original): A sealing apparatus as claimed in claim 1, wherein the upper mold includes a main surface and includes a cavity on the main surface, and wherein the semiconductor wafer is sandwiched at its periphery by the main surface of the upper mold other than an area where the cavity is formed

and the lower mold whereby the resin is not formed on the periphery of the semiconductor wafer.

Claim 25 (original): A sealing apparatus as claimed in claim 24, wherein the cavity is located at a position corresponding to the area, wherein the upper mold further includes a gate connected to the cavity and cull connected to the gate, wherein the gate is located at a position corresponding the periphery of the semiconductor wafer, and where the cavity is formed deeper than the gate.

Claim 26 (original): A sealing apparatus as claimed in claim 25, wherein the width of the gate is expanding toward the cavity.

Claim 27 (original): A sealing apparatus as claimed in claim 25, wherein the upper mold includes a air vent, which is located at a position opposite to the gate, for releasing air in the cavity when the semiconductor wafer is sealed.

Claim 28 (original): A sealing apparatus as claimed in claim 26, wherein the upper mold includes a air vent, which is located at a position opposite to the gate, for releasing air in the cavity when the semiconductor wafer is sealed.

Claim 29 (original): A sealing apparatus as claimed in claim 24, further comprising a projection member being formed underneath the center of a back surface the lower mold, which is opposite to the uneven surface.

Claim 30 (original): A sealing apparatus as claimed in claim 24, further comprising ejection pins formed in the lower mold, the ejection pins pushing the semiconductor wafer up after the semiconductor wafer is sealed by the resin.

Claim 31 (original): A sealing apparatus as claimed in claim 30, wherein the ejection pins are disposed symmetrically against the center of the area.

Claim 32 (original): A semiconductor device manufacturing mold for setting a semiconductor wafer having semiconductor elements on its surface in order to seal the surface by resin, comprising:

an upper mold; and

a lower mold having an area where the semiconductor wafer is mounted, the lower mold having an uneven surface in the area.

Claim 33 (original): A semiconductor device manufacturing mold as claimed in claim 32, wherein the uneven surface is formed by an electric discharging process in coarse condition.

Claim 34 (original): A semiconductor device manufacturing mold as claimed in claim 33, wherein the area is a first area, the uneven surface is formed within a second area, which is in the first area, and the uneven surface is not formed in the periphery of the first area.

Claim 35 (currently amended): A semiconductor device manufacturing mold as claimed in claim 33, wherein ~~wherein~~ the uneven surface has a roughness in a range between 8 μ m and 12 μ m.

Claim 36 (original): A semiconductor device manufacturing mold as claimed in claim 34, wherein the uneven surface has a roughness in a range between 8 μ m and 12 μ m.

Claim 37 (original): A semiconductor device manufacturing mold as claimed in claim 32, wherein the uneven surface is formed by slits.

Claim 38 (original): A semiconductor device manufacturing mold as claimed in claim 37, wherein the slits are formed in parallel to each other.

Claim 39 (original): A semiconductor device manufacturing mold as claimed in claim 37, wherein the area is a first area, the slits is formed within a second area, which is in the first area, and the slits are not extended to the periphery of the first area.

Claim 40 (original): A semiconductor device manufacturing mold as claimed in claim 38, wherein the area is a first area, the slits is formed within a second area, which is in the first area, and the slits are not extended to the periphery of the first area.

Claim 41 (original): A semiconductor device manufacturing mold as claimed in claim 32, wherein the uneven surface is formed by a single spiral slit.

Claim 42 (original): A semiconductor device manufacturing mold as claimed in claim 41, wherein the area is a first area, the single spiral slit is formed within a second area, which is in the first area, and the single spiral slit is not extended to the periphery of the first area.

Claim 43 (original): A gate of a sealing device having a mold in which a semiconductor wafer having semiconductor elements on its surface is set in order to form a resin layer on the semiconductor wafer by introducing a melted resin from a resin supplier, the gate introducing the melted resin into the mold from a part of a periphery of the semiconductor wafer, and a depth of the gate is lower than the thickness of the resin layer.

Claim 44 (original): A gate as claimed in claim 43, wherein a width of the gate is expanding from the resin supplier toward the semiconductor wafer.

Claim 45 (original): A sealing apparatus for sealing a semiconductor wafer having semiconductor elements on its surface by resin, comprising:

an upper mold;

a lower mold having an area where the semiconductor wafer is mounted;

and

a shock absorber, which is formed under the lower mold, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and lower molds.

Claim 46 (original): A sealing apparatus for sealing a semiconductor wafer having semiconductor elements on its surface by resin, comprising:

an upper mold;

a lower mold having an area where the semiconductor wafer is mounted;

and

shock absorbers, which are formed under the lower mold, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold, the shock absorbers being disposed symmetrically against the center of the area.

Claim 47 (original): A sealing apparatus as claimed in claim 45, wherein the shock absorber is formed by a metallic compression spring.

Claim 48 (original): A sealing apparatus as claimed in claim 46, wherein each shock absorber is formed by a metallic compression spring.

Claim 49 (original): A sealing apparatus as claimed in claim 45, wherein the shock absorber is a first shock absorber, further comprising:

a first block having a first recess, the lower mold being contained in the first recess;

a second block having a second recess, the first block being contained in the second recess; and

a second shock absorber, which is formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 50 (original): A sealing apparatus as claimed in claim 45, wherein the shock absorber is a first shock absorber, further comprising:

a first block having a first recess, the lower mold being contained in the first recess;

a second block having a second recess, the first block being contained in the second recess; and

second shock absorbers, which are formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 51 (original): A sealing apparatus as claimed in claim 49, wherein the second shock absorber is formed by a metallic compression spring.

Claim 52 (original): A sealing apparatus as claimed in claim 50, wherein each second shock absorber is formed by a metallic compression spring.

Claim 53 (original): A sealing apparatus as claimed in claim 46, wherein the shock absorbers are first shock absorbers, further comprising:

a first block having a first recess, the lower mold being contained in the first recess;

a second block having a second recess, the first block being contained in the second recess; and

a second shock absorber, which is formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 54 (original): A sealing apparatus as claimed in claim 46, wherein the shock absorbers are first shock absorbers, further comprising:

a first block having a first recess, the lower mold being contained in the first recess;

a second block having a second recess, the first block being contained in the second recess; and

second shock absorbers, which are formed under the second block, buffering stress from the upper mold when the semiconductor wafer is sandwiched by the upper and the lower mold.

Claim 55 (original): A sealing apparatus as claimed in claim 53, wherein the second shock absorber is formed by a metallic compression spring.

Claim 56 (original): A sealing apparatus as claimed in claim 54, wherein each second shock absorber is formed by a metallic compression spring.

Claims 57-91 (cancelled):